

ELECTRONICALLY FILED ON 03 JULY 2007.

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of inventor(s):

Michel Luc Cote et al.

Application No. **10/799,073**

Confirmation No. **8538**

Filing Date: **12 March 2004**

Title: **Design and Layout of Phase Shifting Photolithographic Masks**

Group Art Unit: 1756

Examiner: Stephen D. Rosasco

CUSTOMER NO. 30437

MAIL STOP AMENDMENT

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

RESPONSE/AMENDMENT

Sir:

In response to the Office Action mailed 05 April 2007, Applicants request the following amendments in the above-referenced application:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 5 of this paper.

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